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| APPLICATION NUMBER | FILING or 371(c)<br>DATE | GRP ART UNIT | FIL FEE REC'D | ATTY.DOCKET.NO | TOT CLAIMS | IND CLAIMS |
|--------------------|--------------------------|--------------|---------------|----------------|------------|------------|
| 10/585,001         | 06/29/2006               | 2881         | 900           | 128591         | 16         | 3          |

**CONFIRMATION NO. 4937**

**CORRECTED FILING RECEIPT**

25944  
OLIFF & BERRIDGE, PLC  
P.O. BOX 19928  
ALEXANDRIA, VA22320

Date Mailed: 08/15/2007

Receipt is acknowledged of this non-provisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. **If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections**

**Applicant(s)**

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**Assignment For Published Patent Application**

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**Domestic Priority data as claimed by applicant**

This application is a 371 of PCT/JP05/00228 01/12/2005

**Foreign Applications**

JAPAN 2004-007948 01/15/2004

**If Required, Foreign Filing License Granted: 03/27/2007**

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is  
**US10/585,001**

**Projected Publication Date:** Not Applicable

**Non-Publication Request:** No

**Early Publication Request:** No

**Title**

An exposure apparatus and device manufacturing method

**Preliminary Class**

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